

European Solutions for the Global Market

Prof. Dr. Hubert Lakner

Chairman of the Board of Directors Fraunhofer Group for Microelectronics

Executive Director Fraunhofer IPMS



















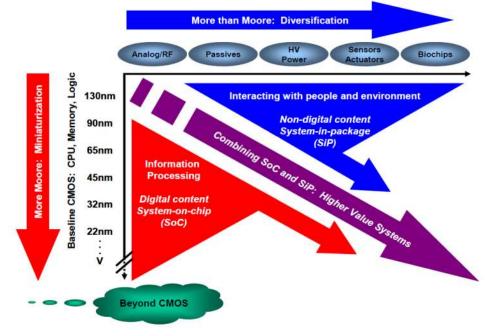
Microelectronic development trends

Micro- and Nanoelectronics are key enabling technologies for all major industrial areas in Germany and Europe

The development cycles are decreasing rapidly in the area of leading-edge technologies (»More Moore«) as well as in the field of microsystems

(»More than Moore«)

New development and solutions for the Internet-of-Things could be generated only by strong cooperation efforts between different expertises

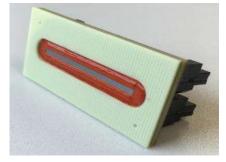


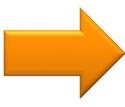




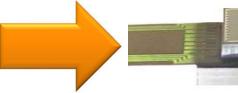


Key parameter Integration level









Classic

System-in-Package (SiP)

System-on-Chip (SoC)

Smaller system dimensions

Lower power consumption

Reduced parasitic effects

Lower cost @ high volumes

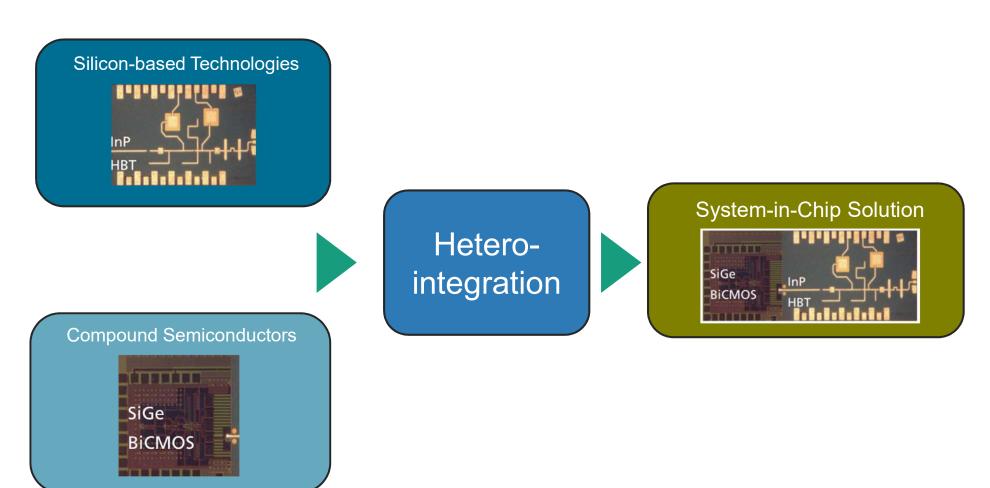








Crossborder Technology Knowledge



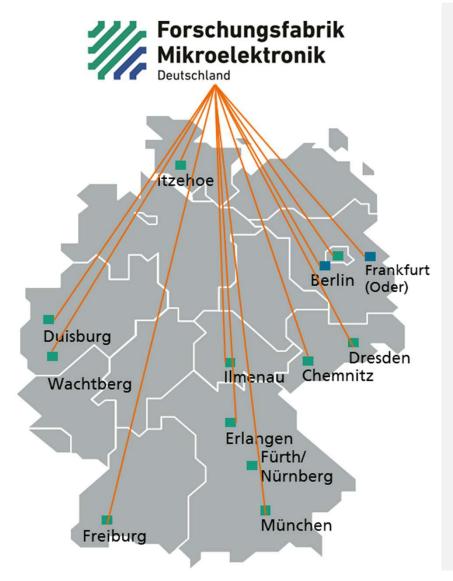
Crossborder knowledge is essential











One-Stop-Shop for developments from wafer technologies to complete systems

- The FMD combines the expertise and infrastructure of 13 Research Institutes to deliver complete developments out of one hand
- The FMD will represent a reorganization of more than 2000 scientists and the necessary equipment for technological research and development under a single, virtual roof
- To prepare the FMD for future developments additional infrastructure investment of 350 Mio. € is planned







FMD One-Stop-Shop



Technology Park 1

Investment 140,6 Million Euro

Silicon-based technologies



Technology Park 2

73,3 Million Euro

Compound semiconductors



Technology Park 3

Investment 43 Million Euro

Heterointegration



Technology Park 4

Investment 83,8 Million Euro

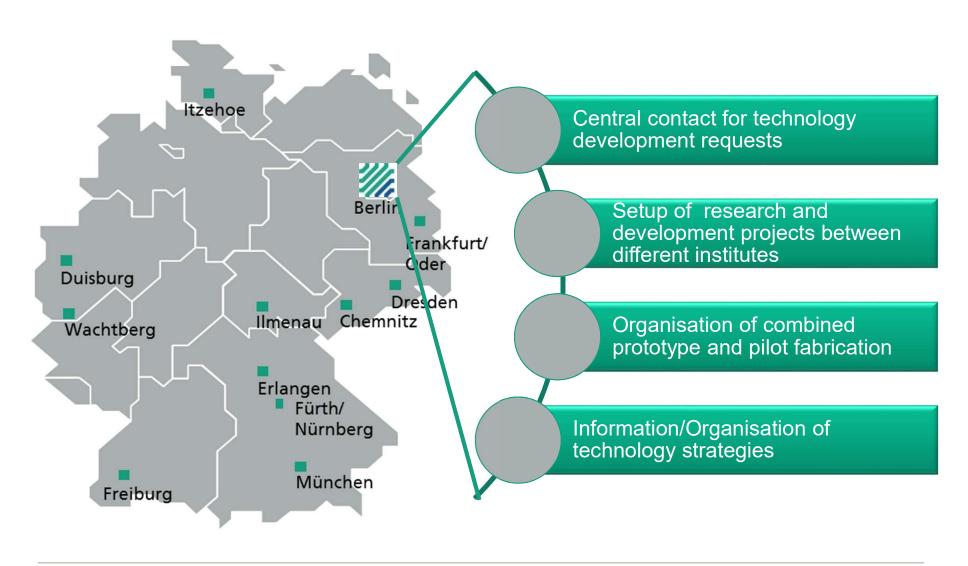
Design, testing and reliability







Joint R&D central access – FMD One-Stop-Shop









Application domain *Industry 4.0*

Smart Sensor Systems for Applications of Industry 4.0

- Interconnected, intelligent sensors are the key components for using modern information and communications technologies in industry. For the conditions of a production plant, however, special robust systems are required, which are equipped with components that record and communicate parameters simultaneously.
- In the »ZEPOWEL« project, methods are being developed to realize towards-zero-power smart sensors and transponders including energy harvester.



© Fraunhofer IIS/EAS, photo: Oliver Killig





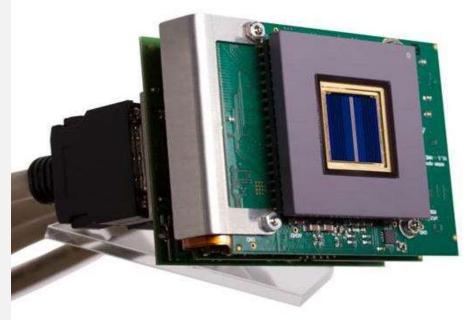




Application domain *Industry 4.0*

"xposure"

- Together with the AIT Austrian Institute of Technology, the fastest line-scan sensor for highly sensitive inspection tasks has been developed. The multiple-linesensor enables colored imaging with a resolution of 0.05 mm at a transport-speed of 36 km/h.
- Thus, the fast sensor can detect even smallest defects on surfaces and can be ideally used for the surface-control of valuable printed material.



© AIT Austrian Institute of Technology





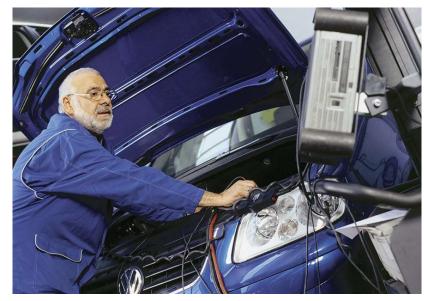






Application domain Mobility and Transport

- Secure and Reliable Nanoelectronics for Vehicle Systems
- Fraunhofer IIS/ EAS is working with partners in the project RESIST to make optimal use of this technology as a key to further advances.
- Design processes for microchips and future systems that will permit even better fulfillment of the high quality and reliability requirements.
- Powerful and robust components that contribute to reducing fuel consumption and CO2 emissions.



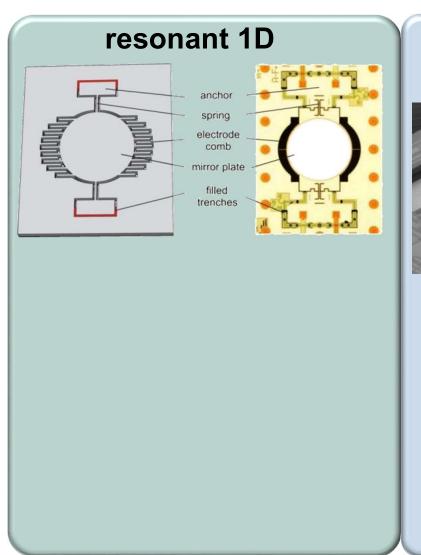
»RESIST« develops among other results an » early warning system«, that will report any electronic degradation to the maintenance service. © MEV-Verlag



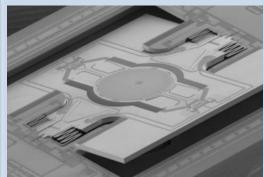




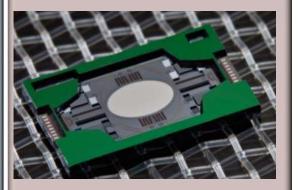
Application domain Mobility and Transport: Micro Scanning Mirrors for LIDAR













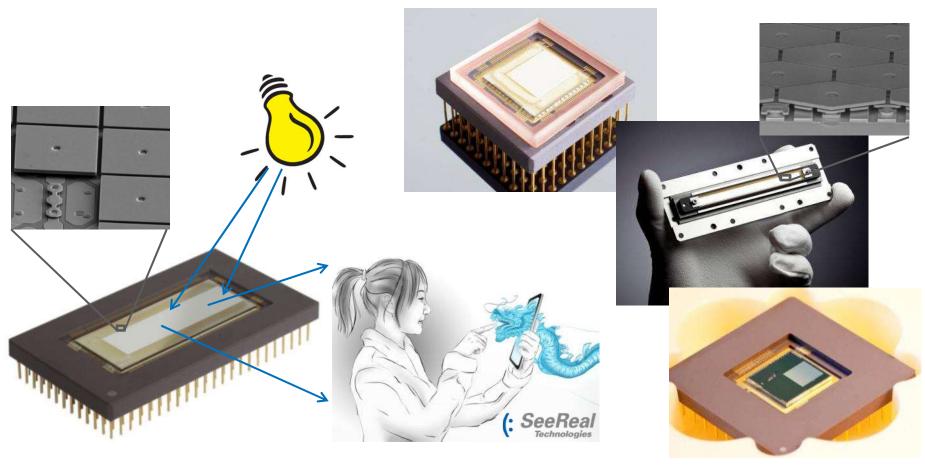


Fraunhofer



Digitale Transformation – Virtual Reality

Computer Generated Holograms by MEMS Spatial Light Modulators



Copyright: SeeReal Technologies, Fraunhofer IPMS









Access for SMEs to State-of-the-Art Microelectronics

Universal Sensor Platform for Internet-of-Things Applications

















Benefits for SME customers

Individualised Products due to modular system architecture and standard components

- Drastically reduced product cost
- Reduction of development cost by factor greater than 40
- Reduction of development time by factor greater than 10
- Digital sovereignty "Made in Europe"
- Access to "Leading-Edge" technologies below 28 nm















Universal Sensor Module

Processing Power | Acceleration

Analog Sensor | Actuator

LED Drive



Summary

- MEMS, sensors and microelectronics enable emerging applications like
 - Holography
 - Autonomous driving
 - Point-of-care diagnostics
 - Advanced medical imaging
 - Portable food quality control
 - Plus other applications like IoT, Industrie 4.0, ...
- R&D for the direct benefit of every citizen, tackling grant societal challenges
- Joint forces in Germany via Research Fab Microelectronics Germany (FMD)







THANK YOU!











HTA alliance, your partners for a stronger Europe









Dr. Georges Kotrotsios

CSEM Centre Suisse d'Electronique et de Microtechnique SA

Jaquet-Droz 1 CH-2007 Neuchâtel Suisse

Phone: +41 79.356.60.16 georges.kotrotsios@csem.ch www.csem.ch

Dr. Laurent Herault

CEA LETI Commissariat à l'Energie Atomique

17, rue de Martyrs 38000 Grenoble France

Phone: +33 670.13.50.11 laurent.herault@cea.fr www-leti.cea.fr

Dr. Mikko Merimaa

VTT Technical Research Centre of Finland Itd.

Vuorimiehentie 3, Espoo FI-02044 VTT Finland

Phone: +358 20.722.79.64 mikko.merimaa@vtt.fi www.vtt.fi

Prof. Dr. Hubert Lakner

Fraunhofer-Institut für **Photonische Mikrosysteme IPMS**

Maria-Reiche-Straße 2 01109 Dresden Germany

Phone: + 49 351.88.23.110 hubert.lakner@ipms.fraunhofer.de www.ipms.fraunhofer.de





